

Supporting Information (file 1 of 2)

# Wettability of Electrospun Films of Microphase-Separated Block Copolymers with 3,3,3-Trifluoropropyl Substituted Siloxane Segments

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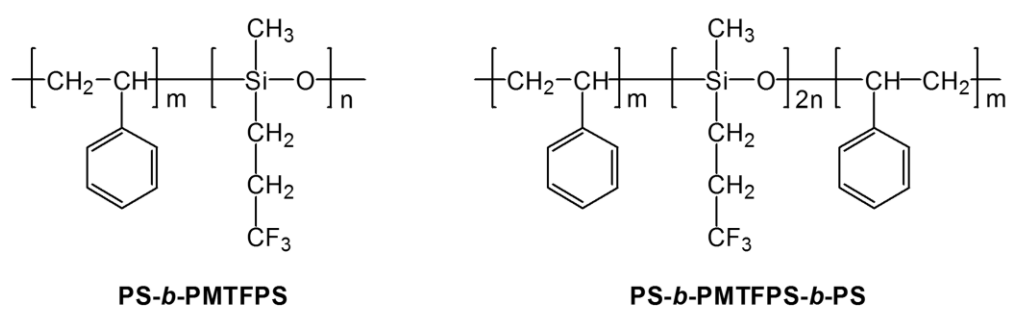
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**Figure S1.** Chemical structures of PS-*b*-PMTFPS diblock copolymers and PS-*b*-PMTFPS-*b*-PS triblock copolymers.

**Table S1.** Glass transition temperature of PS precursors, PS-*b*-PMTFPS diblock copolymers and PS-*b*-PMTFPS-*b*-PS triblock copolymers.<sup>a</sup>

Sample	$T_{g, \text{ homo-PS }} (^\circ\text{C})^b$	$T_{g, \text{ PS }} (^\circ\text{C})^c$	$T_{g, \text{ PMTFPS }} (^\circ\text{C})^d$
S <sub>198</sub> FS <sub>26</sub>	104	98	— <sup>e</sup>
S <sub>106</sub> FS <sub>54</sub>	99	97	−66
S <sub>105</sub> FS <sub>97</sub>	99	97	−68
S <sub>100</sub> FS <sub>191</sub>	99	98	−69
S <sub>99</sub> FS <sub>111</sub> S <sub>99</sub>	98	96	−67
S <sub>95</sub> FS <sub>175</sub> S <sub>95</sub>	98	96	−68

<sup>a</sup> The glass transition temperature ( $T_g$ ) was measured with a Q100 differential scanning calorimetry (DSC) (TA Instruments Inc.) calibrated with indium. After annealed at 150 ~ 160 °C, the samples were quenched down to −120°C at the maximum cooling rate of the instrument, and then scanned at a heating rate of 10°C /min from −120°C up to 150 °C.

<sup>b</sup> Glass transition temperature of PS precursors.

<sup>c</sup> Glass transition temperature of PS block in block copolymers.

<sup>d</sup> Glass transition temperature of PMTFPS block in block copolymers.

<sup>e</sup> The glass transition temperature of PMTFPS block was difficult to be clearly discerned due to a short length of PMTFPS block.

**Table S2.** Contact angles and roll-off angles of salad oil on the electrospun films.

Sample <sup>a</sup>	salad oil <sup>b</sup>			
	static (°)	advancing (°)	receding (°)	roll-off (°)
S <sub>198</sub> FS <sub>26</sub>	131.7±1.4	135.9±0.4	127.0±1.9	8.9
S <sub>106</sub> FS <sub>54</sub>	137.2±5.2	140.2±1.5	132.2±1.3	8.0
S <sub>105</sub> FS <sub>97</sub>	143.6±1.6	145.7±1.2	140.0±1.8	5.7
S <sub>100</sub> FS <sub>191</sub>	143.4±1.6	145.1±1.4	139.0±1.4	6.1
S <sub>99</sub> FS <sub>111</sub> S <sub>99</sub>	138.7±2.1	141.0±1.2	135.0±1.0	6.0
S <sub>95</sub> FS <sub>175</sub> S <sub>95</sub>	139.1±3.7	143.4±1.1	137.6±1.2	5.8

<sup>a</sup> The concentration of electrospinning solutions: (1) 15wt% in DMF: S<sub>100</sub>FS<sub>191</sub>; (2) 25wt% in DMF: S<sub>198</sub>FS<sub>26</sub>, S<sub>105</sub>FS<sub>97</sub>; (3) 25wt% in DMF and THF (1/1, v/v): S<sub>99</sub>FS<sub>111</sub>S<sub>99</sub>, S<sub>95</sub>FS<sub>175</sub>S<sub>95</sub>; (4) 30wt% in DMF and THF (1/1, v/v): S<sub>106</sub>FS<sub>54</sub>. Electrospinning conditions: tip-to-plate distance = 15 cm; humidity = 38%; flow rate = 0.6 mL/h; spinning voltage = 15 kV.

<sup>b</sup> Colored by Oil Red O (1-(2,5-Dimethyl-4-(2,5-dimethylphenylazo)phenylazo)-2-naphthol) with a concentration of 0.4mg/mL.

**Table S3.** Contact angles and roll-off angles of white mineral oil on the electrospun films.

Sample <sup>a</sup>	white mineral oil <sup>b</sup>			
	static (°)	advancing (°)	receding (°)	roll-off (°)
S <sub>198</sub> FS <sub>26</sub>	126.6±2.5	131.4±1.1	120.6±0.9	10.8
S <sub>106</sub> FS <sub>54</sub>	130.1±3.5	134.7±1.9	125.4±1.8	9.3
S <sub>105</sub> FS <sub>97</sub>	140.7±2.9	143.7±1.2	137.0±1.1	6.7
S <sub>100</sub> FS <sub>191</sub>	141.7±1.4	143.6±0.9	137.1±1.7	6.5
S <sub>99</sub> FS <sub>111</sub> S <sub>99</sub>	138.1±1.2	139.4±1.2	133.2±0.6	6.2
S <sub>95</sub> FS <sub>175</sub> S <sub>95</sub>	138.2±5.2	139.5±0.4	133.1±1.1	6.4

<sup>a</sup> The concentration of electrospinning solutions: (1) 15wt% in DMF: S<sub>100</sub>FS<sub>191</sub>; (2) 25wt% in DMF: S<sub>198</sub>FS<sub>26</sub>, S<sub>105</sub>FS<sub>97</sub>; (3) 25wt% in DMF and THF (1/1, v/v): S<sub>99</sub>FS<sub>111</sub>S<sub>99</sub>, S<sub>95</sub>FS<sub>175</sub>S<sub>95</sub>; (4) 30wt% in DMF and THF (1/1, v/v): S<sub>106</sub>FS<sub>54</sub>. Electrospinning conditions: tip-to-plate distance = 15 cm; humidity = 38%; flow rate = 0.6 mL/h; spinning voltage = 15 kV.

<sup>b</sup> Colored by Oil Red O (1-(2,5-Dimethyl-4-(2,5-dimethylphenylazo)phenylazo)-2-naphthol) with a concentration of 0.4mg/mL.

**Table S4.** Contact angles and roll-off angles of hexadecane on the electrospun films.

Sample <sup>a</sup>	hexadecane <sup>b</sup>			
	static (°)	advancing (°)	receding (°)	roll-off (°)
S <sub>198</sub> FS <sub>26</sub>	116.6±1.7	119.8±0.9	105.9±1.4	13.9
S <sub>106</sub> FS <sub>54</sub>	122.6±3.2	124.5±1.0	113.3±1.7	11.2
S <sub>105</sub> FS <sub>97</sub>	134.2±4.1	135.3±1.4	126.2±0.7	9.1
S <sub>100</sub> FS <sub>191</sub>	136.5±3.3	137.6±1.3	129.3±1.1	8.3
S <sub>99</sub> FS <sub>111</sub> S <sub>99</sub>	134.5±0.7	138.3±0.7	129.4±1.2	8.9
S <sub>95</sub> FS <sub>175</sub> S <sub>95</sub>	135.0±2.4	137.8±1.2	130.3±1.3	7.5

<sup>a</sup> The concentration of electrospinning solutions: (1) 15wt% in DMF: S<sub>100</sub>FS<sub>191</sub>; (2) 25wt% in DMF: S<sub>198</sub>FS<sub>26</sub>, S<sub>105</sub>FS<sub>97</sub>; (3) 25wt% in DMF and THF (1/1, v/v): S<sub>99</sub>FS<sub>111</sub>S<sub>99</sub>, S<sub>95</sub>FS<sub>175</sub>S<sub>95</sub>; (4) 30wt% in DMF and THF (1/1, v/v): S<sub>106</sub>FS<sub>54</sub>. Electrospinning conditions: tip-to-plate distance = 15 cm; humidity = 38%; flow rate = 0.6 mL/h; spinning voltage = 15 kV.

<sup>b</sup> Colored by Oil Red O (1-(2,5-Dimethyl-4-(2,5-dimethylphenylazo)phenylazo)-2-naphthol) with a concentration of 0.4mg/mL.

**Table S5.** Surface composition of the thin films of block copolymers determined by ARXPS at 30° and 60 °takeoff angle.

Sample <sup>a</sup>	Si 2p (%)		C 1s (%)		O 1s (%)		F 1s (%)		X (%) <sup>b</sup>	
	60 °	30 °	60 °	30 °	60 °	30 °	60 °	30 °	60 °	30 °
S <sub>198</sub> FS <sub>26</sub>	7.6	9.9	77.1	71.5	8.8	11.4	6.5	7.2	56.5	71.3
S <sub>106</sub> FS <sub>54</sub>	10.1	12.9	61.5	56.2	10.1	12.4	18.3	18.6	79.2	95.5
S <sub>105</sub> FS <sub>97</sub>	12.8	14.1	49.5	45.9	13.2	13.2	24.5	26.9	101.5	110.3
S <sub>100</sub> FS <sub>191</sub>	11.1	12.7	53.2	49.9	11.6	11.9	24.1	25.5	90.9	100.8
S <sub>99</sub> FS <sub>111</sub> S <sub>99</sub>	9.7	10.2	57.4	53.1	10.5	12.1	22.3	24.6	80.9	86.7
S <sub>95</sub> FS <sub>175</sub> S <sub>95</sub>	12.3	12.7	50.3	46.9	11.9	14.0	25.5	26.4	98.9	104.1

<sup>a</sup> The thin films were prepared by spin coating on the aluminum foil (0.1 mm thick, 99.9% metals basis) from a concentration of 1.0 wt% in THF. The solvent was allowed to evaporate in air at room temperature, and then the films were further annealed at 120 °C under vacuum over 24 hours.

<sup>b</sup> X is the PMTFPS molar fraction at the surface, which is estimated by the carbon to silicon atomic ratios (C/Si) and given by the equation  $C/Si = [4X + 8 (1-X)]/X$ . It needs to be noted that some values of X are greater than 100%, which is likely caused by the interactions of fluorines with adjacent silicon atoms (Reference: Owen, M. J. Surface Tension of Polytrifluoropropylmethylsiloxane. *J. Appl. Polym. Sci.* **1988**, 35, 895–901), and then more silicon atoms arrange at the outmost layer of block copolymer films.